



- (51) **International Patent Classification:**  
*H01L 21/302* (2006.01)
- (21) **International Application Number:**  
PCT/US2013/041634
- (22) **International Filing Date:**  
17 May 2013 (17.05.2013)
- (25) **Filing Language:** English
- (26) **Publication Language:** English
- (30) **Priority Data:**  
61/648,937 18 May 2012 (18.05.2012) US  
61/695,548 31 August 2012 (31.08.2012) US
- (71) **Applicant:** **ADVANCED TECHNOLOGY MATERIALS, INC.** [US/US]; 7 Commerce Drive, Danbury, CT 06810 (US).
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- (81) **Designated States** (*unless otherwise indicated, for every kind of national protection available*): AE, AG, AL, AM,

AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU, RW, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.

- (84) **Designated States** (*unless otherwise indicated, for every kind of regional protection available*): ARIPO (BW, GH, GM, KE, LR, LS, MW, MZ, NA, RW, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, RU, TJ, TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

**Published:**

- *with international search report (Art. 21(3))*
- *before the expiration of the time limit for amending the claims and to be republished in the event of receipt of amendments (Rule 48.2(h))*

- (88) **Date of publication of the international search report:**  
20 February 2014



(54) **Title:** AQUEOUS CLEAN SOLUTION WITH LOW COPPER ETCH RATE FOR ORGANIC RESIDUE REMOVAL IMPROVEMENT

(57) **Abstract:** A cleaning composition and process for cleaning post-chemical mechanical polishing (CMP) residue and contaminants from a microelectronic device having said residue and contaminants thereon. The cleaning compositions include at least one quaternary base, at least one amine, at least one corrosion inhibitor, and at least one solvent. The composition achieves highly efficacious cleaning of the post-CMP residue and contaminant material from the surface of the microelectronic device while being compatible with barrier layers.

**A. CLASSIFICATION OF SUBJECT MATTER****H01L 21/302(2006.01)i**

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

H01L 21/302; C11D 1/00; C11D 3/30; C11D 1/62; B08B 7/00; H01L 29/78; B24B 7/00; C11D 3/04; B65D 69/00; G03F 7/42

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Korean utility models and applications for utility models

Japanese utility models and applications for utility models

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

eKOMPASS(KIPO internal) &amp; Keywords: CMP, residue, clean, low-k dielectric, barrier layer, quaternary, amine, corrosion inhibitor and solvent

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	KR 10-2011-0086092 A (ADVANCED TECHNOLOGY MATERIALS, INC.) 27 July 2011 See abstract, paragraphs [0005], [0021]-[0027], [0046]-[0077] and claims 1-18.	22-25
Y		1-4, 21, 27
Y	US 2012-0001262 A1 (HUANG SOON KANG et al.) 05 January 2012 See abstract, paragraphs [0016]-[0026] and figures 1-2B.	1-4, 21
Y	US 2012-0028870 A1 (JEFFREY A. BARNES et al.) 02 February 2012 See abstract, paragraphs [0045]-[0064] and claim 1.	27
A	US 2009-0227483 A1 (WEN DAR LIU et al.) 10 September 2009 See abstract, paragraphs [0032]-[0043] and claim 1.	1-4, 21-25, 27
A	US 2004-0152608 A1 (CHIEN-PIN SHERMAN HSU) 05 August 2004 See abstract, paragraphs [0012]-[0029] and claim 1.	1-4, 21-25, 27

 Further documents are listed in the continuation of Box C. See patent family annex.

\* Special categories of cited documents:

"A" document defining the general state of the art which is not considered to be of particular relevance

"E" earlier application or patent but published on or after the international filing date

"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of citation or other special reason (as specified)

"O" document referring to an oral disclosure, use, exhibition or other means

"P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&amp;" document member of the same patent family


Date of the actual completion of the international search

23 December 2013 (23.12.2013)

Date of mailing of the international search report

**24 December 2013 (24.12.2013)**

Name and mailing address of the ISA/KR


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**INTERNATIONAL SEARCH REPORT**International application No.  
**PCT/US2013/041634****Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)**

This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1.  Claims Nos.:  
because they relate to subject matter not required to be searched by this Authority, namely:
  
2.  Claims Nos.: 18  
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:  
Claim 18 is unclear, because it refers to multiple dependent claim 17 which does not comply with the third sentence of PCT Rule 6.4(a).
  
3.  Claims Nos.: 5-17, 19-20, 26  
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

**Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)**

This International Searching Authority found multiple inventions in this international application, as follows:

1.  As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
  
2.  As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
  
3.  As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
  
  
  
  
  
  
  
  
  
  
4.  No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

**Remark on Protest**

- The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
- The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
- No protest accompanied the payment of additional search fees.

**INTERNATIONAL SEARCH REPORT**

Information on patent family members

International application No.

**PCT/US2013/041634**

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
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		EP 2098911 A3	09/03/2011
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